Ĺ	u		
И	u	1	/

			N
	Application No.	Applicant(s)	
Notice of Allowability	10/082,228 Examiner	TATSUURA ET AL.	
Notice of Americanity			
	Edna Wong	1753	
The MAILING DATE of this communication applied All claims being allowable, PROSECUTION ON THE MERITS herewith (or previously mailed), a Notice of Allowance (PTOLNOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.5	IS (OR REMAINS) CLOSED in 85) or other appropriate commor RIGHTS. This application is s	n this application. If not included unication will be mailed in due course. <b>THIS</b>	ive
1. $\boxtimes$ This communication is responsive to <u>Amendment dated</u>	l February 25, 2005.		
2. The allowed claim(s) is/are <u>30-46</u> .			
3. $\boxtimes$ The drawings filed on <u>26 February 2002</u> are accepted by	by the Examiner.		•
4.  Acknowledgment is made of a claim for foreign priority  a)  All b)  Some* c)  None of the:  1.  Certified copies of the priority documents h  2.  Certified copies of the priority documents h  3.  Copies of the certified copies of the priority         International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:  Applicant has THREE MONTHS FROM THE "MAILING DAT noted below. Failure to timely comply will result in ABANDO THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  5.  A SUBSTITUTE OATH OR DECLARATION must be sure INFORMAL PATENT APPLICATION (PTO-152) which  6.  CORRECTED DRAWINGS ( as "replacement sheets") r  (a)  including changes required by the Notice of Drafts;  1) hereto or 2)  to Paper No./Mail Date  (b)  including changes required by the attached Examin Paper No./Mail Date  Identifying indicia such as the application number (see 37 CF)	ave been received.  ave been received in Application documents have been received.  TE" of this communication to file on the submitted. Note the attached EX gives reason(s) why the oath of the submitted.  Decrease of the submitted of the submitted of the submitted.  Decrease of the submitted of	on No. 09/571,864.  Id in this national stage application from the a reply complying with the requirements  AMINER'S AMENDMENT or NOTICE OF redeclaration is deficient.  In (PTO-948) attached  In the Office action of	
each sheet. Replacement sheet(s) should be labeled as such	in the header according to 37 Cl	R 1.121(d).	
7. DEPOSIT OF and/or INFORMATION about the deattached Examiner's comment regarding REQUIREMENT AND ADDRESS OF THE PROPERTY OF			
Attachment(s)  1. Notice of References Cited (PTO-892)	5. ☐ Notice of Ir	formal Patent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-94	l8) 6. ⊠ Interview S	ummary (PTO-413),	
3. Information Disclosure Statements (PTO-1449 or PTO/S		/Mail Date <i>February 24, 2005</i> . Amendment/Comment	
Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Depos		Statement of Reasons for Allowance	
of Biological Material	9. 🔲 Other	- Sanowag	
		edna wong Primary exammer	

Application/Control Number: 10/082,228

Art Unit: 1753

## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Claims **30-38** are allowable over the prior art of record because the prior art does not teach or suggest an apparatus for electrodeposited film formation comprising an electrolyte solution bath and a mode-locked laser whose pulse with is less than a picosecond.

The prior art does not contain any language that teaches or suggests the above. *Melcher et al.* do not teach a mode-locked laser. Mode-locking inherently creates pulses of picoseconds. The fact that Melcher utilizes a chopper to get pulsing indicates that the continuous multimode or single mode argon laser (col. 3, lines 40-44) is not the same thing as mode-locking. Therefore, a person skilled in the art would not have been motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Claims **39-46** are allowable over the prior art of record because the prior art does not teach or suggest an apparatus for electrodeposited film formation comprising an electrolyte solution bath and a pulse laser with an electric field in the order of tens of GW/cm<sup>2</sup> and whose pulse width is less than a picosecond.

The prior art does not contain any language that teaches or suggests the above. Melcher et al. do not teach a pulse laser with an electric field in the order of tens of GW/cm². Melcher et al. teach an intensity preferably between about 10² to 10<sup>6</sup> W/cm² (col. 3, lines 48-50). Therefore, a person skilled in the art would not have been Application/Control Number: 10/082,228

**Art Unit: 1753** 

motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 4:00 pm, Flex.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Page 4

Edna Wong Primary Examiner Art Unit 1753

EW March 21, 2005